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# **Crumpled Graphene Oxide for Enhanced Room Temperature Gas Sensing: Understanding the Critical Roles of Surface Morphology and Functionalization**

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# **Abstract**

This work fundamentally explores graphene oxide morphology and functionality with regard to room temperature gas sensing performance. Highly-oxidized, crumpled graphene oxide (HO-CGO) was synthesized using a scalable, aerosol-based process. To minimize sample-to-sample synthesis variability, HO-CGO and flat graphene oxide material controls were thermally reduced allowing for a serial library of graphene oxide materials with comparable shape and surface chemistries. Room temperature sensitivity to ethanol was then systematically evaluated as a function of curing temperature, time (i.e., degree of thermal reduction), and morphology. HO-CGO showed the strongest response after one hour of reduction at a relatively mild temperature (220 °C), which removed most of the oxygen functionality. In contrast, flat graphene oxide sheets at the same C/O ratios showed no response. Density functional theory (DFT) and *ab initio* molecular dynamics (AIMD) simulations of ethanol interactions with these material surfaces were employed to develop a mechanistic understanding of the observed enhanced sensing response. Adsorption energy calculations revealed that point defects have the most favorable adsorption energy for ethanol, followed by oxygen functionalities, and pristine graphene, respectively. In addition, AIMD on a simulated crumpled structure of graphene oxide showed that ethanol molecules prefer to adsorb at/in the geometrical valleys of the CGO structure. Enhanced gas sensing performance of CGO is proposed to be a function of structural valleys, which act as both stable sites for oxygen defects and preferential binding sites for the ethanol molecules, whose adsorption occurs through physisorption, with a substantial contribution  $(\sim 50\%)$  derived from dispersive forces. This work directly demonstrates the benefits of the crumpled structure of CGO, with concave morphological regions, compared to other carbon-based materials, and informs its processing and incorporation into functional room temperature gas sensing devices.

# **1.1 Introduction**

Historically, work on gas sensing has focused on single-species gas sensors.<sup>1</sup> Accordingly, traditional approaches to the design and synthesis of sensing materials have focused on lock-andkey type mechanisms.2, 3 However, single analyte sensors can often suffer from poor selectivity, exhibiting cross-sensitivity to a number of different gases. Further, a tradeoff exists between the selectivity and the post-response recovery of the active material, as selectivity tends to be a function of strong binding via specific interactions, whereas rapid post-response recovery tends to be a function of weak interactions, typical of non-specific forces, such as van der Waals forces. To manage this tradeoff, gas sensor arrays allowing for analyte differentiation, have gained attention.<sup>4</sup> For successful application, such complex devices should be rationally designed, which requires a mechanistic understanding of how different sensor materials interact with (potential) analytes. Such mechanistic understanding can be gained by systematically studying how specific sensor materials interact with different classes of target compounds. For scalability, libraries of sensing materials should be easy to synthesize and modify. Towards this, carbon-based nanomaterials are strong candidates for such arrays due to high sensitivity, large surface area, and ease of tailoring.<sup>5</sup> However, to date, we often fall short of predict complex, combitorial analyte-sensor response(s) for carbon materials that are key for rational design and scale-up.<sup>6</sup>

Pioneering work on gas sensing with carbon-based, nanoscale materials began with the demonstration of semiconducting single-walled carbon nanotubes (SWNTs) as highly sensitive, room temperature gas sensors for  $NO<sub>2</sub>$  and  $NH<sub>3</sub>$ .<sup>7</sup> Further studies revealed that SWNT defect sites played an important role in sensing response.8-10 Specifically, a relatively small amount of chemical functionalization through oxidation (around 2%) significantly affects sensitivity and selectivity of the sensors for several gases.<sup>8</sup> Surface area enhancements provided further gains in conductivity and allowed for room-temperature detection limit(s) down to individual gas molecules.11, 12 As with carbon nanotubes, further exploration revealed that the sensing response of pristine graphene also depends on the type and geometry of defects.<sup>13</sup>

Sensing devices made of carbon nanotubes and pristine graphene sheets are currently limited by relatively high production cost, complex fabrication routes, and limited durability/robustness.<sup>14</sup> Further, the application of SWNTs for sensor arrays is largely restricted by the difficulty of controlling the synthesis of semiconducting SWNTs, as samples typically consist of mixtures of both metallic and semiconducting SWNTs, which remain difficult to separate.<sup>2</sup> Such realities result in fabrication complexity, low sensor yields, and poor reproducibility.<sup>15</sup> In addition to synthesis constraints, device fabrication using SWNTs or graphene typically require relatively complex processes, including patterning and top-down synthesis techniques, which increase device cost and response variability.<sup>14</sup>

Based on the demonstrated role of defects and functional groups observed for carbon nanotubes and graphene sensors, research has evolved towards the use of chemically modified graphene (CMG). One interesting class of CMG is reduced graphene oxide (RGO), which is inexpensive, easy to produce, while containing a diverse range of reactive oxygen functional groups which can be modified to balance conductivity with active surface sites.<sup>16</sup> RGO sensor response depends on molecular adsorption to both low-energy adsorption sites, such as sp<sup>2</sup>-bonded carbon, and higherenergy adsorption sites, such as defects and functional groups.<sup>17</sup> The reduction process and the distribution of functional groups play key roles in the sensing performance of RGO.<sup>17-22</sup>

While RGO can potentially overcome fabrication challenges posed by graphene, RGO sheets tend to aggregate, decreasing the surface area exposed to target gases and significantly decreasing performance in comparison to monolayer graphene or graphene oxide  $(GO)$ .<sup>22</sup> As an alternative to RGO sheets, nanostructured carbon materials, including porous and foam-like structures, have been recently explored;<sup>14, 22-24</sup> however, surfactant-free and simple fabrication of hierarchical graphene structures is still complex. Crumpled graphene oxide (CGO) materials possess a low tendency for aggregation while maintaining high specific surface area and exceptional electronic properties similar to those of flat graphene sheets. Hence, CGO provides a potentially unique material solution which can be incorporated into thin films and integrated in scalable and reproducible sensors.25, 26 Additionally, synthesizing CGO via a furnace aerosol reactor (FuAR) is a scalable and well-studied process for producing nanostructured GO.<sup>25, 27</sup> In contrast to other 3D synthesis methods, this continuous process does not require catalysts, vacuum conditions, or high temperatures. The FuAR process is appealing for synthesizing libraries of materials for gas sensor arrays as the morphology (size and degree of crumpling) and functionalization can be easily tuned by varying parameters such as the concentration of GO in the aerosol droplet, the furnace temperature, and residence time.27-29 In addition, highly stable crumpled particles resist aggregation and compression, limiting the impact of the processing history on material performance.<sup>25</sup> Unlike carbon nanotubes, these materials feature inherent oxygen functionality that can be easily and efficiently controlled by varying the synthesis temperature.30-32 Moreover, the crumpled ridges of the CGO sheets can be considered as line defects, which can enhance adsorption for sensing applications. Crumpled graphene oxide, in contrast to 2D flat analogues, has been applied for gas sensing in only a few studies.<sup>33-35</sup> Chen et al. focused on the role of the enhanced surface area of crumpled graphene-based nanosheets in gas sensing performance, but did not explore the roles of point defects, line defects, or functional groups.<sup>33</sup>

In this work, we fundamentally explore the role of functional groups on the gas-phase sensing response of CGO for ethanol, as a model, polar organic analyte. Specifically, we compare the performance of CGO structures to the performance of flat GO sheets to determine the effect of morphology on the ethanol sensing response. We employ both experimental observations and theoretical calculations to elucidate interactions of ethanol with sensor materials – determining binding affinities and charge transfer mechanisms at defect sites, along ridges, and on functional groups. Results provide key insights toward a mechanistic understanding of the combined interactions between functional groups, defects, and morphology, which is necessary to realize the high potential for the application of crumpled graphene oxide materials in gas sensor arrays.

# **1.2 Methods**

#### **1.2.1 Preparation of Graphene Oxide**

Graphene oxide (GO) was prepared via modified Hummers' method.<sup>36</sup> First, 50 mL of concentrated sulfuric acid (H2SO4**,** 96.4% purity) was added to 2 grams of graphite powder. The mixture was cooled to 0 °C in an ice bath. After the mixture was allowed to return to room temperature, six grams of potassium permanganate  $(KMnO<sub>4</sub>)$  were added. The suspension was then heated to 50 °C and stirred for 2 hours. The elevated temperature in this step, as compared to the temperature in previous studies conducted by our group, improved the graphene oxide oxidation efficiency.<sup>37</sup> The initial synthesis of a highly oxidized graphite oxide powder allowed for the subsequent synthesis of highly oxidized crumpled graphene oxide (HO-CGO), which will be discussed in later sections. The mixture was again cooled to 0 °C in an ice bath and diluted with

350 mL of DI water. An aqueous hydrogen peroxide solution  $(H_2O_2, 30\%)$  was added to the diluted mixture with stirring until the gas was no longer seen to be evolving. The suspension was then rinsed with DI water and vacuum filtered. After the graphite oxide was allowed to dry for 24 hours, the powder was redispersed in DI water and sonicated with a probe sonicator for 3 hours to exfoliate the stacked sheets into single sheets of graphene oxide. The suspension was centrifuged at 10,000 rpm for 3 hours was, and the supernatant, the final graphene oxide solution, was decanted.

### **1.2.2 Graphene Oxide Modification: Crumpling and Reduction**

The single sheets were then crumpled in a furnace aerosol reactor (Lindber/Blue M 1100 °C Tube Furnace), shown in **Figure 1a** schematic. GO coupons were fed into the reactor as a 300 ppm aqueous solution via a Collison nebulizer (BGI Incorporated). The six jet nebulizer was operated at 14 psi, resulting in a flow rate of 12.4 L/min and roughly 3  $\mu$ m droplets.<sup>27</sup> Droplets were delivered by  $N_2$  carrier gas into the furnace via a ceramic tube with an inner diameter of 25 mm and a length of 1 m. The residence time of the particles in the heated zone, set at 400  $^{\circ}$ C, was  $\sim$ 1.6 seconds.

### **1.2.3 Characterization of Graphene Oxide**

The morphology and size of the flat GO and the crumpled GO (CGO) samples were characterized using transmission electron microscopy (TEM, TecnaiTM Spirit, FEI Co.), field emission scanning electron microscopy (SEM, Nova NanoSEM 230, FEI Co.), and atomic force microscopy (AFM, Veeco Nanoman). The TEM samples were prepared by drop-casting aqueous GO solution onto a carbon film on 300 mesh copper grids (electron microscopy sciences, CF300-Cu). AFM of the thin films was performed with a scan size of 30 µm (fully covering the area between interdigitated electrodes), at a rate of 0.1000 Hz. Information on the electrical bond and

functionality of the surface was obtained with X-ray photoelectron spectroscopy (XPS, PHI 5000 Versa Probe II, monochromatic Al Kα X-ray Source at 1486.6 eV). The peaks were fit using a mixed fit of 80% Gaussian and 20% Lorentzian characters in the PHI Multipak software. Calibration was carried out by aligning the C 1s peak (C-C) with its reference line at 284.8 eV (associated with graphitic carbon), and a Shirley background subtraction was performed. For the fitting, the full width at half maximum (FWHM) values was fixed at 1.2 eV for all peaks and the positions of each deconvolution peak were maintained within 0.2 eV of the assigned position. Three measurements were made on each sample at different locations. Finally, the defect structure was examined via Raman spectroscopy (Renishaw InVia Reflex confocal Raman spectrometer). The Raman spectra were collected using a 514.5 nm laser excitation at 10% power, focused on the sample using a 50X objective.

#### **1.2.4 Graphene Oxide Sensor Fabrication**

Sensor fabrication was performed by drop-casting 60  $\mu$ L of 100 ppm aqueous GO/CGO solution onto interdigitated electrodes. The electrodes were fabricated on Si (100) substrate (380 μm thickness, n-type, University Wafers) with a 100 nm layer of  $SiO<sub>2</sub>$  grown via plasma-enhanced chemical vapor deposition (PECVD, Nanofab, Oxford Instruments). Interdigitated electrode patterns with 40 interdigitated fingers at 20 µm spacing were patterned using a laser writer (DWL66+ laser lithography system, Heidelberg Instruments) followed by thermal evaporation and deposition of a 10 nm chromium adhesion layer and a 70 nm gold layer. The as-deposited films were then dried overnight in a vacuum oven at room temperature. To remove any remaining bulk and interstitial water, the films were heated for 1 hour at 60 °C. To eliminate the device-to-device variability associated with the drop-casting procedure, the as-deposited films were then incrementally reduced via low-temperature thermal reduction by incrementally heating them in a 220 °C  $\pm$  1 °C, vacuum oven at 0.08MPa (DZF-6020 Vacuum Oven, MTI Corporation) for 4 minutes, 1 hour, 4 hours, and 24 hours.<sup>38</sup> Fabricated sensor(s) photo is shown in **Figure S1**.

#### **1.2.5 Gas-Sensing Measurements**

Gas sensing measurements were performed on a previously described system.<sup>39</sup> The sensors were preconditioned by flowing dry, filtered air at 750 sccm (standard cubic centimeter per minute) for one hour prior to the pulsed testing. Each pulsed test consisted of five cycles alternating between five minutes of dry, filtered air with ethanol at different concentrations (gas) followed by five minutes of dry, filtered room air (degas). Throughout the cycling process, the air flow was maintained at 750 sccm. Five different concentrations were tested: 20, 40, 50, 100, and 200 ppm.

#### **1.2.6 Computational Methods**

#### *1.2.6.1 Density Functional Theory (DFT) Calculations*

Theoretical calculations were conducted with the Vienna *ab initio* simulation package (VASP version 5.3.5).40, 41 The projector augmented wave (PAW) method in conjunction with the frozencore approximation was used with a 500 eV energy cutoff.<sup>42, 43</sup> The generalized gradient approximation (GGA) with the formulation proposed by Perdew–Burke–Ernzerhof (PBE) was employed for the exchange-correlation functional.<sup>44</sup> The pristine graphene  $(pG)$  sheet was modeled as a periodic slab consisting of 72 carbon atoms with dimensions of 14.736  $\AA \times 12.762$  Å and a C-C bond distance of 1.418 Å (**[Figure 2](#page-25-0)a**). Graphene oxide (GO) was modeled by functionalizing the pristine graphene sheet via adsorbing a hydroxyl, an epoxide, or a carbonyl group on one side of the pristine graphene sheet, while defective graphene (dG) was modeled by removing one carbon atom from the pristine slab (**[Figure 2](#page-25-0)b-e**). A vacuum spacing of 20 Å was imposed above the sheets to avoid spurious interactions between periodic images in the z-direction.

For the adsorption calculations, an ethanol molecule was allowed to adsorb on one side of the slab and dipole corrections were employed to produce accurate adsorption energies. During geometry optimization, all atoms were allowed to relax using the conjugate gradient algorithm until the Hellmann-Feynman forces on each ion were smaller than 0.01 eV/Å, with an overall energy convergence criterion of 10−5 eV/cell. For Brillouin zone integration, k-meshes were generated automatically using the Monkhorst–Pack (MP) method with a  $(5\times5\times1)$  k-point mesh. Because noncovalent interactions were expected to play an important role in adsorption, the empirical van der Waals corrections, as prescribed by Grimme (DFT-D3) with Becke-Jonson (BJ) damping, were considered in all calculations.<sup>45</sup>

### *1.2.6.2 Ab initio Molecular Dynamics (AIMD) Simulation*

To investigate the interactions between ethanol and wrinkled graphene (wG) under ambient conditions, *ab initio* molecular dynamics (AIMD) simulations were conducted within the canonical (NVT) ensemble in VASP. The wrinkled graphene sheet was modeled by introducing a ripple at the center of the pristine sheet with an amplitude-to-period ratio of 0.4. To simulate a large interface for interactions between the wrinkled sheet and ethanol molecules, a  $p(2\times2)$  slab consisting of 288 carbon atoms with surface dimensions of 29.472  $\AA \times 25.524$  Å was simulated, and a vacuum space of 20 Å was imposed above the slab as was done for the DFT calculations. At the beginning of the simulation, four ethanol molecules were placed randomly at a large distance  $({\sim} 5 \text{ Å})$  above the slab. The atomic positions of the wrinkled graphene sheet were fixed throughout the simulation in order to retain the rippled structure, while the positions of the ethanol molecules were allowed to change. Similar to the DFT calculations, the GGA-PBE functional with the D3(BJ) dispersion corrections was employed. An energy cutoff of 300 eV was employed for the AIMD simulations, and the k-space was sampled only at the *Γ*-point, given the large size of the

simulation box. A Nosè-Hoover thermostat was applied to conduct constant temperature simulations at  $T = 298$  K. A time step of 0.5 femtoseconds (fs) was used to integrate the equations of motion, and 30 picoseconds (ps) trajectories (60,000 steps) were generated for the adsorbateadsorbent system.

# **1.3 Results and Discussion**

#### **1.3.1 Material Synthesis and Characterization**

As-synthesized GO and CGO samples were characterized by AFM and TEM to compare their morphology and structure. Figure 1b-e shows representative morphologies observed for flat graphene oxide sheets and corresponding 3D structure after being crumpled in the furnace aerosol reactor (FUAR). Smaller in diameter than their flat counterparts, CGO particles have distinct ridges that effectively create peaks and valleys. The size distribution of the crumpled graphene oxide was analyzed by measuring the diameter of over 100 particles in TEM images, using ImageJ software. The average particle size was roughly 500 nm, with over 80% of the particles in the range of 300-700 nm (**Figure S2**). XPS analysis was employed to determine the oxidation state of as-synthesized material and for different synthesis phases. GO starting material was highly oxidized, with a C/O ratio of 1.4±0.07. The starting ratio is much lower than what is typically observed for GO synthesized by the modified Hummers' method due to the increased temperature (35 °C  $\rightarrow$  50 °C) employed in this work to enhance bulk oxidation processes.<sup>30</sup> Two factors control the morphology of CGO particles synthesized in a FUAR. The first,  $F_a$ , is the capillary/crumpling force generated through the evaporation of the aqueous droplet: $27,46$ 

$$
F_a = P_{vap} a_s = P_d exp \left( \frac{4 \sigma v_m}{D_d RT_d} \right) \pi D_d^2, \tag{Equation 1}
$$

where  $P_{vap}$  is the vapor pressure of the solvent on the droplet,  $a_s$  is the surface area of the droplet,  $P_d$  is the vapor pressure of the solvent at the surface of the droplet,  $\sigma$  is the surface tension of the liquid,  $v_m$  is the molar volume of the liquid,  $D_d$  is the droplet diameter, R is the gas constant, and  $T_d$  is the droplet surface temperature. This force must be large enough to overcome the confinement force,  $F_c$ , and thus crumple the particle.

$$
F_c = AC^{1/\delta D} D_p^{-1/\delta} D_d^{-3/\delta D},
$$
 (Equation 2)

where A is a constant  $(A = Y 2^{\frac{D-3}{\delta D}} h^{1+\frac{D-3}{\delta D}} \rho_m^{-\frac{1}{\delta D}})$ , C in the mass concentration (kg/m<sup>3</sup>),  $\delta$  is the  $\frac{1}{\delta D}h^{1+\frac{D-3}{\delta D}}h$  $\frac{\delta \overline{\delta \overline{D}}}{\delta \overline{D}}\rho_m-\frac{1}{\delta \overline{D}}$  $\delta^{(D)}$ , C in the mass concentration (kg/m<sup>3</sup>),  $\delta$ force scaling exponent for a self-avoiding sheet  $(0.25)$ , D is the characteristic fractal dimension of GO (2.54), and  $D_p$  is the mobility diameter (nm). At 400 °C,  $F_a$  is greater than  $F_c$  and the sheets are crumpled. Previous studies show that, at this temperature, some of the oxygen-containing functional groups remain, resulting in a C/O ratio of  $3.2 \pm 0.1$ .<sup>30, 31</sup> Unlike the forces required for crumpling, the reduction of the graphene oxide sheets is dependent on reaction kinetics, and therefore, on the amount of time the material is exposed to a given temperature and also the oxidation state of the starting material. By leveraging the kinetics of the reduction process and starting with a highly oxidized form of GO, we are able to synthesize a highly oxidized crumpled graphene oxide (HO-CGO), in contrast to previously synthesized CGO. The C/O ratio of the HO-CGO synthesized at 400 °C was 2.0, which is more typical of GO synthesized by the traditional modified Hummers' method.<sup>47</sup>

#### **1.3.2 Sensor Fabrication and Characterization**

The GO and CGO solutions were drop-cast onto sensing substrates, maintaining the same mass loading between the two samples. The morphologies of the as-deposited CGO films are shown in **[Figure 3](#page-26-0)**. In addition to imaging surface morphology, the surface area and roughness of each 30

 $\mu$ m  $\times$  30  $\mu$ m analysis area were intermittently characterized throughout the reduction process by AFM (**Figure S3**). Initially, the CGO films had a roughness  $(R_q)$  of 181 nm and a surface area of

1,143  $\mu$ m<sup>2</sup>. Following reduction for 20 hours, the CGO films had a surface roughness of 171 nm and a surface area of  $1,077 \mu m^2$ . Visual inspection of the AFM images of the surface also showed that the CGO materials maintain their crumpled morphology, i.e. not reverting to a flat or rippled structure following prolonged reduction. The GO film had a roughness  $(R_q)$  of 75 nm and a surface area of 955  $\mu$ m<sup>2</sup>. The AFM images of the GO thin films reveal a layered, slightly wrinkled graphene oxide structure. In addition, the calculated surface area difference percentage representing the difference between the three-dimensional surface area and its two-dimensional footprint, was 4.89% for GO and 24.75% for CGO, as to be expected for a 3D porous structure. For the same mass-loading over the same area, we can see that the surface area of the films and the access of the surface to analyte vapors is significantly improved with CGO.

CGO is both compression- and aggregation-resistant, and can be readily dispersed in both apolar and polar solvents.<sup>25</sup> One of the key requirements for solution-based printing/manufactoring is the successful (stable) dispersion of nanoparticles to avoid aggregation. Compared to flat reduced graphene oxide sheets, CGO offers the potential to simplify sensor fabrication through low cost, simple printing techniques.<sup>48</sup> These printing techniques can be used on flexible substrates, which offer improved portability and sturdiness. In addition, in a previous study using a similar annealing technique for thermal reduction, portions of the flat graphene oxide films delaminated from the surface.<sup>38</sup> Thermal reduction of GO sheets is suggested to cause delamination through the rapid evaporation of intercalated water and/or the evolution of gas(es) during the reduction process. In contrast, CGO thin films did not show any delamination from the

surface in these experiments. The inherint structure of the CGO thin films, with spacing and pores for the gases and water to escape through, likely aids in preventing such processes.<sup>49</sup>

Sensing performance is a function not only of access to binding sites, but also of the number of available binding sites. As mentioned, oxygen-containing functional groups and defects on the surface are thought to act as preferential binding sites for chemical vapors. Therefore, we measured not only the surface area but also the oxygen-containing functional groups on the surface and the defect structure, using XPS and Raman spectroscopy, respectively.

As can be seen from the XPS spectrum scan of the C1s peak in **Figure S4,** the starting materials for both the HO-CGO and GO, have two peaks, which is indicative of oxygen-containing functional groups on the surface. For both CGO and GO, after 1 hour of reduction at 220 °C, the second peak was reduced to a shoulder of the C-C peak. The same trend can be seen in the C/O ratio. After 1 hour of reduction, the GO and CGO have the same C/O ratio of 3.2. As shown in **[Figure 4](#page-27-0)a**, the C1s peak was deconvoluted to determine the percent area of functional groups on the surface. In accordance with previous work, the five most common oxygen functionalities were identified and fit: C-C (284.8 eV), C-OH (286.2 eV), C-O-C (287.1 eV), C=O (287.7 eV), and COOH (288.8 eV).<sup>47, 50</sup> The C-C area ratio for CGO started at 54% and gradually increased to roughly 70%. Remaining oxygen-containing functional groups on the surface after reduction at 220 °C are primarily attributed to hydroxide groups.

To probe the surface defects, Raman spectroscopy was intermittently employed on films throughout the reduction process. The Raman spectra, taken for different processing temperatures, shown in **[Figure 4b](#page-27-0)** (CGO) and **Figure S5** (GO), are scaled to the height of the G-peak for

comparison. Initially, spectra scans of both HO-CGO and GO show similar structures, with a prominent D-peak around 1355 cm<sup>-1</sup> and a broad G-peak in the range of 1580-1615 cm<sup>-1 51</sup> The Gpeak for GO gradually shifts down with increased thermal reduction (**[Figure 4](#page-27-0)c**), indicating restoration of a hexagonal network of carbon atoms with defects.<sup>52</sup> In addition, the D-peak intensity gradually increased with reduction (**Figure S5**), which suggests the formation of small but numerous regions of aromatic carbons. HO-CGO did not show a change in the intensity of the D-peak, rather the more prominent trend was the formation of a shoulder on the G-peak of the CGO films. This type of G-peak splitting has been observed to be a function of curvature-induced strain in both carbon nanotubes and graphene sheets.<sup>53, 54</sup> For both the GO and the HO-CGO, physically and chemically induced defects exist. As shown in the AFM images, the graphene oxide thin films have large wrinkles whereas each individual crumpled graphene oxide particle has wrinkles as well as ridges and valleys, all of which can be considered as extended/line defects.<sup>55</sup> Indeed, in both spectrums, a 2D band with two peaks is seen, (**Figure S5**), which is indicative of physical, but not chemical, defects.<sup>55</sup> The failure of the CGO D-peak to follow a trend similar to the established change in the GO peak following thermal reduction indicates that the defect structure of the material is driven primarily by physical and not chemical defects. In addition, the FWHMs of the D- and G-peaks are broad, which was previously observed for few-layer wrinkled graphene.<sup>55</sup> The FWHMs of the CGO films were consistently larger than those of their GO counterparts, as shown in **[Figure 4](#page-27-0)d** that, can again, be explained by the physical inhomogeneity of the crumpled samples, which is a function of the inconsistent morphology of the line defects of individual crumpled particles. Overall, the Raman spectra demonstrate that both the GO and CGO films remain highly disordered (carbon environment) upon reduction, even following the removal of oxygen-containing functional groups. A more detailed study of the role of crumpling on Raman spectroscopy should be performed on single crumpled sheets to elucidate the differences between the chemical and physical defect structure responses.

#### **1.3.3 Sensing Response**

The response of the HO-CGO sensor to ethanol is shown in **[Figure 5](#page-28-0)**. Initially, the sensor has a relatively high baseline resistance of 92 MOhms and shows a very weak response to ethanol at elevated concentrations (>100 ppm). After thermal reduction for four minutes at 220 °C, the sensor begins to show improved performance. A response, although somewhat noisy, can now be seen in the lower concentration range. There is a decrease in the baseline resistance of the material, which is consistent with the XPS results which indicated carbon reduction and partial restoration of the  $sp<sup>2</sup>$  structure. However, there is only a small change in the functionalization of the material compared to the dried sensor. As previously discussed, the Raman spectra of the HO-CGO sensor showed no change in the D-band intensity or the G-band intensity in this first reduction step. In contrast, following the reduction of the material for 1 hour at 220 °C, the sensor exhibits excellent sensing response, showing clear response in the lowest concentration range explored (**Figure 5d**). For this system, HO-CGO material has reduced surface oxidation (**[Figure 4](#page-27-0)**), with a C/O ratio of 3.2±0.29. For comparison, flat graphene oxide films which also have a C/O ratio of 3.2±0.18, exhibit no sensing response. The large difference in response suggests morphology plays a critical role in sensing performance.

 After an additional 3 hours of reduction, the baseline resistance of the sensor continues to decrease (**Figure 5e**); however, few additional functional groups are removed from the surface, which maintains a relatively constant C/O ratio of 3.2±0.44 (**[Figure 4](#page-27-0)**). The decrease in resistance can be attributed to the restructuring of the defective surface, which improves the electrical conductivity, as observed by others.<sup>38</sup> Although there is still a response at lower concentrations, the magnitude of the response is 50% less than the response observed in Figure 5c, after being normalized for the change in baseline. Finally, sensors were thermally reduced for 24 hours (**Figure 5f**). Again, there was a decrease in the baseline resistance of material; however, the change was much smaller than observed in previous reduction steps, despite the much longer reduction time. The small change in reduction after four hours implies that the limit of restructuring and return of the sp<sup>2</sup> structure of the crumpled material was approached (within the 24-hour reduction period). Again, the sensing response was diminished but still observed, with a response measured at 50 ppm.

#### **1.3.4 Theoretical Calculation Insights**

## *1.3.4.1 DFT Calculations of Ethanol Adsorption on Graphene/Graphene Oxide*

DFT calculations were performed to investigate the energetics and configurations of ethanol adsorption on pristine graphene (pG), on defective graphene (dG), and graphene sheets with different functional groups, namely epoxide, hydroxyl, and carbonyl, used collectively to simulate graphene oxide (GO). The energy of adsorption,  $E_{ads}$ , is defined as the difference in the total energy when the ethanol molecule is adsorbed on the slab, and when it is isolated in vacuum:

$$
E_{ads} = \Delta E_{tot} = -[E_{slab + mol} - (E_{slab} + E_{mol})],
$$
 (Equation 3)

where  $E_{surf + mol}$  is the total energy of the slab with the adsorbed ethanol molecule in the optimized adsorption configuration, and  $E_{slab}$  and  $E_{mol}$  are the optimized energies of the clean slab and the isolated ethanol molecule, respectively. According to this definition, a positive value for the adsorption energy indicates an exothermic process (i.e., the adsorption is thermodynamically favorable). Calculated energies for ethanol adsorption on graphene oxide with different functional

groups are listed in **[Table 1](#page-31-0)**. Ethanol adsorption energies are within the range of 0.223 to 0.511 eV, indicating a relatively moderate physisorption process. The ethanol adsorption on the defective graphene sheet (dG) is the most thermodynamically stable ( $E_{ads} = 0.511$ ), followed by the adsorption on graphene oxide (GO) with the hydroxyl, carbonyl, and epoxide groups, respectively. Adsorption on pristine graphene (pG) is the least stable, which suggests that the presence of point defects and oxygen-containing functional groups enhances the adsorption of ethanol on graphene.

**[Figure 6](#page-29-0)** depicts the stable adsorption configurations of ethanol on the pG, dG, and GO sheets. The relaxed structures show that the adsorption of ethanol induces minor deformations in graphene oxide and defective graphene, while no changes are observed in the structure of pristine graphene after adsorption. For GO with a carbonyl group, the C=O bond elongates by 0.5%, while for the epoxide group the C-O-C bond elongates by 0.7%. For GO with a hydroxyl group, the O-H bond elongates by 1.5%, while the C-O bond shrinks by 1.8%. For defective graphene, ethanol adsorption pushes one of the under-coordinated carbon atoms out of plane by 0.651 Å. Moreover, a close-range electrostatic interaction appears to take place between ethanol's hydrogen and the oxygen atoms of GO with a carbonyl group (bond distance 1.855 Å) and an epoxide group (bond distance 2.042 Å), while for GO with a hydroxyl group, a similar interaction takes place between GO's hydrogen and ethanol's oxygen (bond distance  $= 1.818$  Å). The results suggest that point defects in defective graphene and functional groups on GO serve as favorable binding sites for the adsorption of polar VOCs.

Long-range van der Waals (vdW) interactions are considered in our calculations based on the empirical dispersion corrections proposed by Grimme (D3) in conjunction with the Becke-Jonson (BJ) damping technique. In this method, the total corrected energy of the system,  $E_{tot}$ , is the summation of the conventional DFT energy,  $E_{DFT}$ , and an additional energy term that accounts for

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dispersive interactions,  $E_{disp}$ <sup>56</sup> Hence, by using a formula similar to the one employed for calculating the adsorption energy, the contribution of dispersive interactions between the surface and the adsorbate molecule can be evaluated as

$$
E_{ads} = \Delta E_{tot} = \Delta E_{DFT} - \Delta E_{disp}
$$
 (Equation 4)

Calculated values of the dispersion energy for the adsorption of ethanol on pG, dG, and GO are given in **[Table 1](#page-31-0)**. For all the studied systems, the contribution of dispersive interactions to the adsorption energy is substantial  $(\geq 50\%)$ . The contribution of dispersive interactions is inversely proportional to the overall adsorption energy, with defective graphene features having the highest adsorption energy and the lowest contribution from dispersive forces (49.86%). In contrast, pristine graphene has almost 100% contribution from dispersive forces. The contribution of dispersive forces to  $E_{tot}$  indicates that the enhanced binding strength for defective graphene comes from the strong electrostatic interactions between functional groups or defects and ethanol. However, for pristine graphene, the adsorption is driven almost exclusivly by vdW interactions.

#### *1.3.4.2 AIMD Simulation of Ethanol Adsorption on Rippled Graphene*

AIMD simulations of ethanol adsorption on a wrinkled graphene slab elucidate the sensing dynamics at room temperature. At the beginning of the simulation, four ethanol molecules are randomly placed at a large distance above the surface  $(\sim 5 \text{ Å})$ , and then allowed to move freely under canonical conditions (NVT) for the entire simulation period. As the simulation proceeds, ethanol molecules gradually descend towards the wrinkled graphene sheet. After rapidly adsorbing to the surface, ethanol molecules start to diffuse laterally across the wrinkled sheet. When visualizing the trajectories taken by the molecules as they diffuse on the surface, it is observed they tend to avoid the peaks of the ripples. Instead, the molecules appear to move along the valleys created by the wrinkled structure, as depicted in **[Figure 7](#page-30-0)**. **[Figure 7a](#page-30-0)** shows the wrinkled sheet of graphene oxide with the carbon atoms color-coded to represent the crests (red), valleys (blue), and hillsides (grey) of the ripples. **[Figure 7](#page-30-0)b** is a heat map of the positions taken by all four ethanol molecules on the surface throughout the simulation period plotted by tracking the x and y coordinates of their oxygen atoms. Trajectories during the first 5 ps are excluded from this analysis. The results suggest that ethanol molecules are more likely to be found in the valleys, rather than on the peaks, of the wrinkled graphene sheet. This behavior can be attributed to the larger surface area provided by the valley-like zones for enhanced vdW interactions, which were shown by the DFT calculations to be the main driver for ethanol adsorption on pristine graphene.

## **1.3.5 Sensing Mechanism**

Two key factors in sensing performance of the CGO thin films are increased access to preferential binding sites and/or an increased number of potential (favorable) binding sites. When considering adsorption sites, a defective surface (attributed to either oxygen-containing functional groups or point defects) creates a more favorable adsorption environment than pristine sheets. Consequently, the as-deposited CGO thin films, with the largest number of oxygen-containing functional groups, were expected to have an enhanced performance. However, the best response for ethanol was observed after the films were reduced for one hour. The difference between the theoretical and experimental results can be explained by the balance between favorable electronic properties and favorable binding sites, as the additional oxygen moieties act not only as preferential binding sites but also as electron-withdrawing groups, resulting in a relatively noisy sensor signal and thus decreased sensor performance. Upon carbon reduction, partial  $sp<sup>2</sup>$  character of the material is restored and, while a sensing response is still observed, sensitivity is significantly decreased. During the reduction of graphene oxide, topological defects and vacancies are created, albiet with kinetic considerations as reduction for longer periods allows for diffusion and coalescence of the defects to restructure into more stable configurations.<sup>57</sup> The increase in the conductivity after four minutes of reduction, despite little to no change observed in the surface functionalization, indicates that structural changes do occur. Based on the theoretical results, which show the most favorable adsorption at point defects, the strong sensing performance observed for the CGO thin films reduced for one hour is attributed to binding at such vacancies. Using a tight-binding molecular dynamics (TBMD) simulation, two neighboring single vacancies have been previously shown to form a double vacancy  $(C_2)$ , also called a 5-8-5 defect, and further work showed these defects are more stable on curved surfaces.<sup>57, 58</sup> The curved ridges and valleys of the CGO particles can act as a collection site for such defects, as the material being reduced effectively minimizes the defect energy. Of note, this also shows that the most reduced form of the material may not necessarily have the best performance, and the synthesis process must be optimized to determine the best response for different VOCs. For a molecule with stronger binding affinity or charge transfer potential, the favorable electronic properties may not be necessary to see a robust response. The role of reduction time on the sensing performance for different classes of compounds should be explored moving forward, as this may offer the opportunity to use the same material, processed for different amounts of time, in an array-type configuration.

The AIMD simulations further underscore the role of CGO morphology with regard to sensing performance. Experimental results demonstrate that CGO thin films have larger surface area compared to their flat counterparts, which increases the overall potential number of interactions between the surface and the target analytes. Additionally, AIMD simulations highlight how the valleys of the crumpled structure are especially important for physisorption processes driven by vdW forces, for which DFT calculations showed contributions between 45-99% of the adsorption energy for ethanol. Further, these valleys likely contain stable point defects that act as preferential binding sites for ethanol molecules. Thus when compared to other engineered carbon nanomaterial counterparts such as fullerenes and carbon nanotubes, whose convex (exposed) surfaces offer comparatively reduced interaction(s) with similar, target analytes, the sensing advantage of CGO becomes clear.

# **1.4 Conclusions**

In this work, highly-oxidized CGO synthesis was demonstrated using a oxidized GO starting material, rather than relying on the furnace temperature during synthesis to control surface derivitization. GO functionalization and morphology were explored to determine their role(s) in gas sensing performance. While theoretical calculations indicate that oxygen-containing functional groups act as favorable binding sites for ethanol, a large number of oxygen-containing functional groups limit the application of the material as a chemiresistive gas sensor due to diminished electronic properties (compared to ethanol sensing signal). In contrast, point defects were shown to be thermodynamically stable adsorption sites for ethanol molecules that do not have the same deleterious effects with regard to electronic structure (compared with oxygen functionality). In addition, the morphology of the material was shown to be a critical variable. Valley topology inherent to CGO enhances the surface area and analyte vdW interactions, while potentially stabilizing point defects. Based on these results the role of both functional groups and morphology are clearly intertwined and should be further explored in conjunction for other classes volatile organic compounds.

In addition to surface tunability, CGO is an attrative material with regard to scale-up synthesis and ease of incorporation into sensing devices. Aggregation-resistance, conferred by the crumpled morphology, enables wet chemical deposition and processing strategies for thin films. In contrast, application of isolated and/or single sheet flat graphene oxide typically requires advanced processing due to aggregation tendancies (i.e. stacking), increasing fabrication costs and variability between devices. It is also notable that the reduction process used in this work is below back-endof-line thermal budgets for semiconductor manufacturing.<sup>38</sup> When taken together, new mechanistic insight (and approach) in this work will inform rational design and application of CGO for a range of possible sensing devices.

## **FIGURES**



**Figure 1** (a) A schematic of the synthesis, deposition, and reduction process of crumpled graphene oxide (CGO). TEM images of the (b) starting graphene oxide (GO) material and (c) the daughter CGO. AFM images and height profiles (insets) of the (d) starting GO material and (e) the daughter CGO.



<span id="page-25-0"></span>**Figure 2** Surface models of (a) pristine graphene, (b-d) graphene oxide with an epoxide, a hydroxyl, and a carbonyl functional groups, respectively, (e) defective graphene, and (f) wrinkled graphene. The brown, white, and red colors represent carbon, hydrogen, and oxygen atoms, respectively.



<span id="page-26-0"></span>**Figure 3** AFM images of the as-deposited (a) few-layer wrinkled graphene oxide thin films and (b) crumpled graphene oxide thin films. SEM images of the as-deposited (c) few-layer wrinkled graphene oxide thin films on sensing substrates and (d) crumpled graphene oxide thin films on sensing substrates.



<span id="page-27-0"></span>**Figure 4** (a) Percent area coverage of functional groups on the crumpled graphene oxide surface determined by deconvolution of the C1s peak for five functional groups, grouped by oxidation state. (b)Raman spectrum of the crumpled graphene oxide thin film taken intermittently during the reduction process. Average value of the (c) G-Peak center and (d) FWHM for GO and CGO films taken intermittently during the reduction process.



<span id="page-28-0"></span>**Figure 5** Response of the CGO thin film to gas profile (a) 5 minute pulses of ethanol (GAS) at concentrations of 20, 40, 50, 100, and 200 ppm, respectively, followed by 5 minute pulses of dry, filtered air (DEGAS) after (b) thermal drying at 60°C for 1 hour, (c) reduction at 220 °C for 4 minutes, (d) reduction at 220 °C for 1 hour, (e) reduction at 220 °C for 4 hours, and (f) reduction at 220 °C for 24 hours.



<span id="page-29-0"></span>**Figure 6.** Optimized configurations of an ethanol molecule adsorbed on (a) pristine graphene, (b-d) graphene oxide with an epoxide, a hydroxyl, and a carbonyl functional group, respectively, and (e) defective graphene. The brown, white, and red colors represent carbon, hydrogen, and oxygen atoms, respectively.



<span id="page-30-0"></span>**Figure 7** (a) The P(2×2) wrinkled slab model consisting of 288 carbon atoms color-coded as follows: crests (red), valleys (blue), and hillsides (grey). (b) Heat map of the positions taken by all four ethanol molecules on the surface throughout the simulation period plotted by tracking the x and y coordinates of their oxygen atoms.

## **TABLES**

<span id="page-31-0"></span>**Table 1** Adsorption energy (eV) and dispersion energy (eV) for the adsorption of ethanol on pristine and defective graphene, and graphene oxide with a hydroxyl, carbonyl, and epoxide groups. The configurations are ranked in descending order from the most stable to the least stable.

Structure	$E_{ads}$ (eV)	$\Delta E_{disp}$ (eV)
Defective Graphene	0.511	0.255
GO - Hydroxyl	0.505	0.304
GO - Carbonyl	0.485	0.301
GO - Epoxide	0.361	0 2 7 1
Pristine Graphene	0 2 2 3	0 2 2 1

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